Loading and Asymmetry Measurements on the NSTX ICRF System*

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What are we up to, and why?

NSTX HHFW system:

- Most complicated rf system on a fusion experiment (I think).
 - 12 current straps, 6 transmitters, strong mutual coupling among straps
- Plasma parameters differ from conventional tokamaks and stellarators
 - Low magnetic field, high harmonic heating ($\omega/\omega_c \approx 10$ for present experiments)
 - High magnetic field pitch angle ($\geq 45^{\circ}$)
- So new, interesting physics regime to study rf heating and coupling

We want to understand how the plasma affects the rf system:

- Coupling of power to the plasma (plasma loading)
- Inductance of each strap
- Inductive coupling between straps

Results will affect the ability of the rf system to

- Heat
- Drive current
- Dynamically change CD efficiency



Design configuration: Each transmitter drives two current straps in resonant loop configuration with decoupling circuits



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We have carried out experiments to directly measure the S-matrix during plasma operation

The S-matrix is the scattering matrix of an unknown electrical circuit with one (or several) input/outputs



$$b = S \bullet a$$

 a_k = amplitude of forward wave down line *k* toward circuit

 b_j = amplitude of reflected wave on line *j* away from circuit

The S-matrix describes the behavior of the rf system *independent* of the circuits that are connected to it.

NSTX has a 6 x 6 S-matrix, with six transmitters and transmission lines.



How do we measure the S matrix?

1. Start with a given a vector, and measure the response (the b vector)

$$b = S \bullet a$$

2. Do this for six *linearly independent a* vectors, combine to make a 6 x 6 A matrix and B matrix.

 $\mathsf{B} = \mathsf{S} \bullet \mathsf{A}$

3. Since the *a* vectors are independent, the inverse of A exists, so $S = B \cdot A^{-1}$

Practically, we do this by firing all six transmitters sequentially in a short time. 35 ms



Basic assumption: Plasma conditions *do not change* during this time.





S-matrix is calculated at different places in rf system From measured quantities, can calc. *a* and *b* voltage vectors at points 4 - 8. Will discuss S4: S-matrix at input to resonant loop and decoupler circuit. Cube voltage Forward and refl. power meas. **1**x **Calculation points** 1 End of current strap 2 Input to antenna feedline 3 Junction of 2 antenna feedlines **2x** ² 4 Source side of decouplers (input to 6-way cross) 5 Input to quarter-wave transformer 6 Load side of stub tuner 7 Source side of stub tuner 8 Location of forward/reflected pwr meas.

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Behavior of diagonal components of S matrix



 $S_{k,k}$ behaves about as expected qualitatively

- Plasma presence drops magnitude of diagonal terms to between 0.5 and 1, magnitude gives plasma loading resistance R. Magnitudes are the same to within experimental error bars
- Presence of plasma also rotates angle of S_{k,k} some angle φ, usually between 0° and 45°, depending on plasma parameters.





Changes of $S_{k,k}$ with plasma parameters

- |S_{k,k}| decreases as gap decreases (in agreement with plasma loading increasing for smaller gap)
- Relatively independent of plasma current



 Relatively independent of plasma current







Behavior of off-diagonal terms

S4 between adjacent loops (looking into antenna loops and decouplers) -

- In vacuum, S4pos = S4neg \approx 0 + 0*j* (decouplers are set to make this so)
- Plasma reduces inter-strap coupling, particularly in positive direction



Note: Significant errors in calculation since off-diagonal terms are substantially smaller than on-diagonal terms, so small errors have greater effect.



Changes of off-diagonal terms with plasma parameters

Inter-strap coupling asymmetry (ratio of S4_{pos} to S4_{neg}) is larger for higher I_p
Asymmetry increases as gap increases (at least for 800 kA shots)



For $I_p = 800$ kA, angle of toroidal field at antenna is $\approx 34^{\circ}$



For $I_p = 300$ kA, angle of toroidal field at antenna is $\approx 18^{\circ}$



Summary – progress has been made, still work to do

Qualitatively good agreement with expectations:

- Higher pitch angle of field line should give larger asymmetry (RANT3D calc.)
- Loading should increase as gap decreases
- Phase angle of diagonal terms should increase as gap decreases (selfinductance of current strap is lowered)

We observe asymmetry to increase as gap increases. Should it?

We're still working to compare *quantitatively* with RANT3D calculations.

